Application No. 10/790,816 Amendment dated June 12, 2006

After Final Office Action of April 11, 2006

AMENDMENTS TO THE CLAIMS

Docket No.: M4065.0607/P607-A

Claims 1-26 (Canceled).

27. (Previously presented) An array of resistance variable memory cells in an

integrated circuit, at least one memory cell comprising a pillar of stacked material

layers on a semiconductor substrate, the stacked layers comprising a first electrode

layer, a chalcogenide glass layer having metal ions diffused therein and being capable

of changing resistance under the influence of an applied voltage, and a second

electrode layer, each layer having [[a]] lateral edges, the lateral edges of each layer

approximately <u>vertically</u> aligned with [[a]] lateral <u>edge</u> <u>edges</u> of each other layer.

28. (Previously presented) The array of Claim 27, further comprising insulating

material in the regions between the pillars.

29. (Original) The array of Claim 28, wherein the insulating material comprises

silicon oxide.

30. (Original) The array of Claim 29, wherein the silicon oxide comprises

tetraethylorthosilicate (TEOS).

31. (Previously presented) The array of Claim 29, wherein the insulating

material further comprises a silicon nitride layer below the silicon oxide that conforms

to the pillars and to the substrate.

32. (Original) The array of Claim 31, wherein the silicon nitride layer is between

5 nm and 50 nm thick.

Claims 33-48 (Canceled).

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- 49. (Previously presented) The array of Claim 27, wherein the metal ions comprise silver ions.
- 50. (Previously presented) The array of Claim 27, wherein at least one of the first and second electrodes is tungsten.